

Surface acoustic wave resonators in the quantum regime

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We present systematic measurements of the quality factors of surface acoustic wave (SAW) resonators on ST-X quartz in the gigahertz range at a temperature of 10 mK. We demonstrate an internal quality factor Q_i approaching 0.5 million at 0.5 GHz and show that $Q_i \geq 4.0 \times 10^4$ is achievable up to 4.4 GHz. We show evidence for a polynomial dependence of propagation loss on frequency, as well as a weak drive power dependence of Q_i that saturates at low power, the latter being consistent with coupling to a bath of two-level systems. Our results indicate that SAW resonators are promising devices for integration with superconducting quantum circuits.

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When a harmonic eigenmode of a mechanical object is well isolated from the environment and cooled to low temperature, it can approach its quantum mechanical ground state where it may be used for fundamental tests of quantum mechanics at a macroscopic scale [1], and for applications in quantum information [2–4] and high-sensitivity detection [5–7]. Research on reaching this quantum limit in mechanical resonators spans a broad range of system sizes and resonant frequencies, from meter-scale mirrors used for gravitational wave detection in the 100 Hz range [8] to nanoscale structures that can reach resonant frequencies above 1 GHz [3,9,10]. Reaching high-quality (Q) factors in such resonators is typically much harder at higher frequencies [11,12], though a Q factor approaching 10^7 has recently been demonstrated at 3.6 GHz in a silicon nanobeam [13].

The integration of mechanical resonators with superconducting electric circuits is actively explored for the realization of on-chip cavity optomechanics [14,15] and mechanical circuit quantum electrodynamics [2–4], for quantum information and detection applications in the microwave domain. In these investigations the mechanical resonance is typically a bulk harmonic mode of a microfabricated object. However, recent experiments have also demonstrated detection of traveling surface acoustic waves (SAWs) at the quantum level [16], as well as their interaction with a superconducting qubit [17]. In this Rapid Communication, we present a systematic study of SAW resonators operated at low temperature $T \approx 10$ mK at or close to the quantum regime $k_B T \ll \hbar f_0$ (where f_0 is the resonant frequency), and show that high-quality factors can be reached, demonstrating their promise for integration with quantum coherent devices.

SAWs are acoustic modes of a crystal that are confined to the substrate surface and can be excited and detected by electric circuits on piezoelectric substrates. They have long been used in electrical engineering with a wide range of applications in communications technology [18]. The interconversion between acoustic and electric signals is achieved using an interdigital transducer (IDT), whose periodicity matches the wavelength of the SAW at a certain frequency. A high-quality reflector for a SAW can be made using an array of shorted or open circuit electrodes, or shallow grooves etched in the

surface, to implement a half wavelength period modulation of the impedance of the wave medium similar to a Bragg grating in optics. A pair of such reflectors placed some distance apart on the substrate forms a Fabry-Perot cavity for SAWs [19], the properties of which can be probed using an appropriately placed IDT (see Fig. 1). Since a SAW typically travels at a few km/s, resonators in the gigahertz range have μm -scale wavelengths, and can thus be fabricated with standard lithographic techniques.

We investigate the quality factors of SAW resonators measured inside a dilution refrigerator at high vacuum and a temperature of $T \approx 10$ mK, under which conditions the dissipation of the SAW is very low. We work with the common SAW substrate ST-X quartz due to its known good performance in resonators at room temperature and weak piezoelectric coupling [18], which results in SAWs with little electrical character and hence good prospects for being weakly electrically coupled to environmental sources of dissipation. The reflectors and IDTs are in all cases made from superconducting aluminum such that at 10 mK ohmic losses can be neglected. The resonators were characterized by measuring the complex reflection coefficient $S_{11}(f)$ at the IDT using a vector network analyzer (VNA). Using an RLC equivalent circuit model, one can derive the following expression for the reflection coefficient close to a single resonance:

$$S_{11}(f) = \frac{(Q_e - Q_i)/Q_e + 2i Q_i(f - f_0)/f}{(Q_e + Q_i)/Q_e + 2i Q_i(f - f_0)/f}. \quad (1)$$

Here Q_i is the internal Q factor of the mode and Q_e is the external Q factor due to the presence of the IDT and measurement port.

The measured single-port SAW resonators can be characterized by a set of geometric parameters illustrated in Fig. 1(a) and listed in Table I. The devices have a frequency response centered at $f_0 = v/\lambda_0$, where $v \approx 3100$ m/s is the SAW velocity and $a = \lambda_0/4$ is the electrode and space width in the lithographically defined mirrors and IDT. The mirrors are separated by an integer number of half wavelengths $d = m\lambda_0/2$ and their reflectivity is given by $R = \tanh(N_g|r_s|) \approx 1$ in the limit $N_g|r_s| \gg 1$, where N_g is the number of electrodes in the mirror and r_s is the reflectivity of each electrode. In this limit, the mirrors have a high reflectivity within their first stopband $\Delta f_{1SB} = 2f_0|r_s|/\pi$. The IDT excites and detects SAWs in a broader frequency range than the mirrors (due

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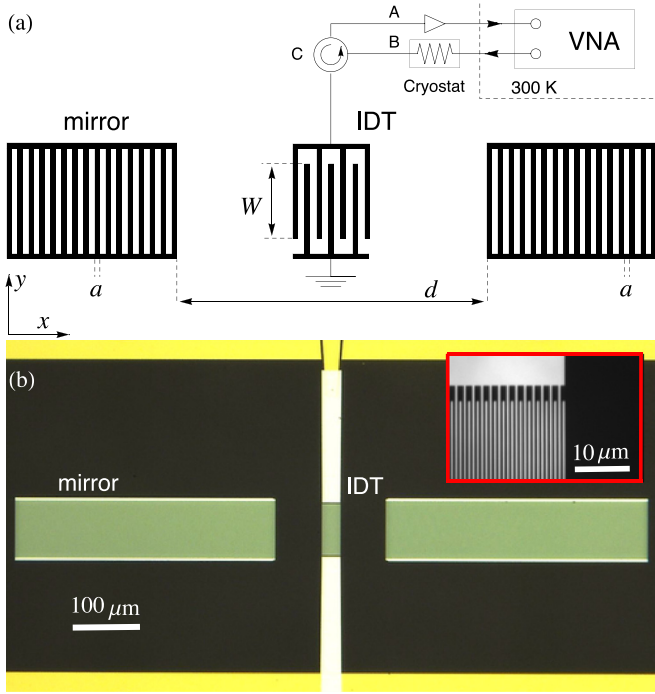


FIG. 1. (a) Schematic of a one-port SAW resonator connected to the measurement setup (A: cryogenic amplifier, B: cold attenuators, C: circulator, and VNA: Vector Network Analyzer). (b) Optical microscope image of a SAW resonator (device r_3 ; see Table I). Inset: magnification of the IDT electrodes of a similar device (q_1).

to being smaller spatially) and has a bandwidth $\Delta f_{\text{IDT}} = 1.8f_0/N_t$, where N_t is the number of electrodes in the IDT [18]. Thus within $|f - f_0| < \Delta f_{\text{ISB}}/2$ the resonator supports high-quality resonant modes, measurable via the IDT. Since the electrode reflectivity is small ($|r_s| \approx 0.2\%$ for our devices), the resonant modes partly penetrate into the mirrors to a penetration depth $L_p = a/|r_s|$ [18]. The devices therefore behave as acoustic Fabry-Perot cavities, with cavity length $L_c = d + 2L_p$ and free spectral range $\text{FSR} = v/L_c = 2f_0/(d/2a + 1/|r_s|)$. When $\text{FSR} > \Delta f_{\text{ISB}}$, a single mode resonance is observed within the mirror stopband, whereas for longer resonators, for which $\text{FSR} < \Delta f_{\text{ISB}}$, multiple resonances are observed (see Fig. 2).

We have initially performed a comprehensive study of SAW resonators at a wavelength of $\lambda_0 = 6 \mu\text{m}$ ($f_0 = 524 \text{ MHz}$) to determine how Q_e and Q_i depend on transducer and grating geometry. This frequency was chosen for compatibility with standard photolithography for which the feature sizes of $a = 1.5 \mu\text{m}$ are achievable and a large number of devices could be fabricated on a single wafer. In this initial investigation we determined that, in accordance with SAW theory [20], the external quality factor follows $Q_e \propto L_c/N_t^2$ and the internal quality factors were limited by grating reflectivity, following

$$Q_g = \frac{\pi(d + 2L_p)}{\lambda_0[1 - \tanh(|r_s|N_g)]}. \quad (2)$$

Based on these observations, we designed a device to realize a high Q_i (within the confines of our chip geometry) with widely spaced long gratings (device p_1 see Table I). This device exhibits $Q_e = 1.16 \times 10^5$, $Q_i = 4.53 \times 10^5$ and the frequency

TABLE I. Parameters of the measured SAW resonators. For device p_1 , the thickness of the aluminum layer is $h = 100 \text{ nm}$ and the geometric parameters are $W = 600a$, $N_t = 51$, and $N_g = 1500$; for all other devices $h = 30 \text{ nm}$, $W = 400a$, $N_t = 71$, and $N_g = 1000$.

Device	a (nm)	\bar{f}_0 (GHz)	$d/2a$	$\bar{Q}_e/10^3$	$\bar{Q}_i/10^3$	$\bar{Q}_i\bar{f}_0/10^{14}$
p_1	1500	0.52	1051	116	453	2.36
r_1	250	3.11	109	24	8.8	0.27
r_2	250	3.12	229	18	10.4	0.32
r_3	250	3.11	429	98	18.8	0.62
r_4	250	3.11	829	167	38.4	1.19
r_5	250	3.10	1229	363	54.5	1.74
r_6	250	3.09	1929	657	74.7	2.32
r_7	250	3.09	2429	473	81.0	2.52
r_8	250	3.10	2829	843	79.6	2.45
r_9	250	3.11	3229	1230	103	3.18
r_{10}	250	3.08	3629	927	109	3.23
q_1	390	2.01	1929	242	171	3.43
q_2	340	2.29	1929	499	126	2.88
q_3	300	2.60	1929	174	108	2.81
q_4	275	2.81	1929	232	78.8	2.21
q_5	225	3.44	1929	445	47.3	1.63
q_6	200	3.83	1929	358	41.0	1.57
q_7	175	4.42	1929	528	40.2	1.78

response is shown in Fig. 2(a). Note that this measurement is not in the quantum regime, since $k_B T \approx hf_0$.

We next proceeded to fabricate SAW resonators at higher frequencies, using electron beam lithography. In Fig. 3(a) we plot Q_i for a series of resonators with $\lambda_0 = 1.0 \mu\text{m}$ ($f_0 \approx 3.1 \text{ GHz}$), for which the distance between the two gratings d was varied over the range 0.05–1.8 mm with all

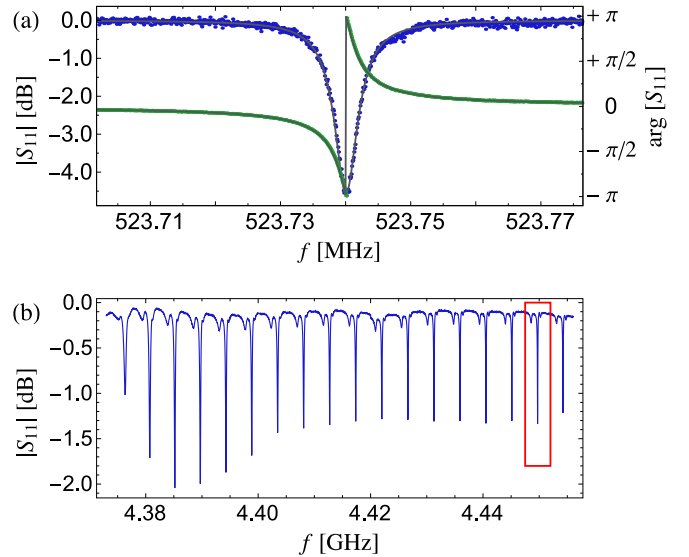


FIG. 2. (a) Magnitude (blue) and phase (green) of the measured reflection coefficient $S_{11}(f)$ of the SAW resonator p_1 . Solid lines are a fit to Eq. (1). (b) Frequency response of device q_7 showing 18 supported high- Q modes. The solid red box indicates the resonant mode measured in Fig. 4. A background due to the measurement setup has been subtracted in both (a) and (b).

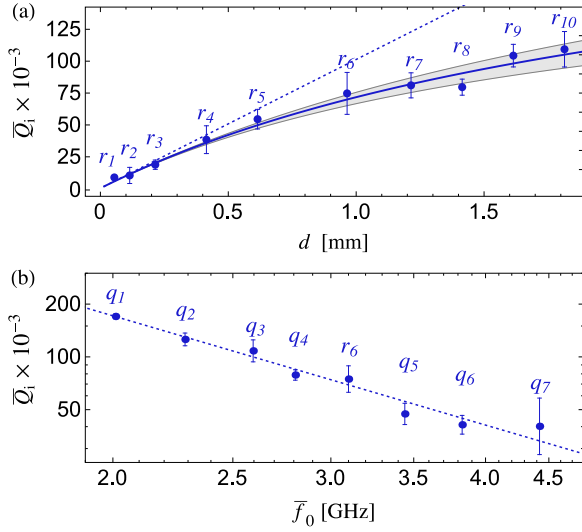


FIG. 3. (a) \bar{Q}_i versus d for devices $r_1 - r_{10}$. Solid line is a fit to Eq. (3). Shaded area indicates one standard deviation of α_p and the dashed line is the linear part of this fit ($\alpha_p = 0$). (b) \bar{Q}_i versus \bar{f}_0 for devices $q_1 - q_7$ and r_6 . Dashed line is a fit to $\bar{Q}_i = c_1 f^{-c_2}$.

other geometric parameters fixed (see Table I). The number of modes seen increases from 1 for device r_1 to 65 for device r_{10} . For devices with more than five modes ($r_5 - r_{10}$), we took the average Q_i for the five modes at the center of the grating stopband where the reflectivity is highest. We expect Q_i to be dominated by the grating reflectivity at low d and saturate at high d due to propagation losses. The data follow this trend and they can be fitted with the following relation:

$$Q_i = \left(\frac{1}{Q_g} + \frac{v\alpha_p}{\pi f_0} \right)^{-1}. \quad (3)$$

From a fit to Eq. (3), we determine the electrode reflectivity to be $|r_s| = 0.002$, and we can place an upper limit on the propagation loss at 3.1 GHz of $\alpha_p|_{10\text{mK}} < 0.015 \text{ mm}^{-1}$ corresponding to a phonon mean free path of $l = 1/\alpha_p \approx 6 \text{ cm}$.

We then moved on to investigate the frequency dependence of Q_i , using a device geometry with large $d = 1929\lambda_0/2$, over the range 2.0–4.4 GHz (devices $q_1 - q_7$; see Table I). These long devices all display around 20 resonant modes within the stopband of the reflectors [see Fig. 2(b) for the frequency response of device q_7]. In Fig. 3(b) we plot the dependence of the average internal quality factor \bar{Q}_i of all modes of each device against average mode frequency \bar{f}_0 . Error bars represent the standard deviation of Q_i from the set of resonant modes. The quality factor is seen to decrease with frequency, and the linear trend observed on a log-log scale indicates a polynomial dependence. We fit the data to $\bar{Q}_i = \pi f / v\alpha_p = c_1 f^{-c_2}$ and find $c_1 = 719 \pm 85$, $c_2 = 2.07 \pm 0.13$. This strongly suggests $\alpha_p \propto f^3$, agreeing with a model developed for SAW propagation loss in the high frequency and low temperature limit [21].

We conclude our investigation with a measurement of the internal quality factor of one of the modes of device q_7 ($f_0 = 4.449 \text{ GHz}$) at low drive powers such that the average resonator phonon population reaches the regime

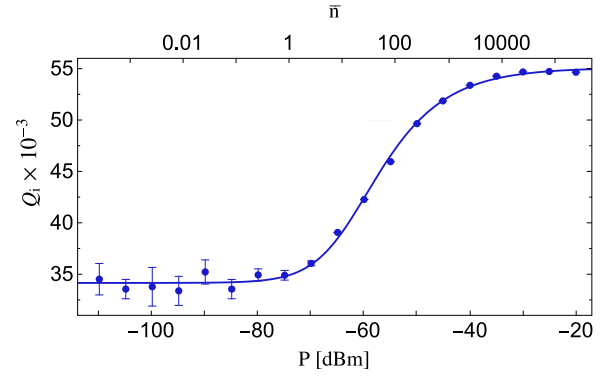


FIG. 4. Q_i versus drive power P for the resonant mode $f_0 = 4.449 \text{ GHz}$ of device q_7 . Solid line: fit to $Q_i = [v\alpha_{\text{TLS}}/(\pi f_0) + 1/Q_{\text{rl}}]^{-1}$; \bar{n} is the mean number of phonons occupying the resonator due to the coherent drive P .

$\bar{n} \ll 1$. Figure 4 shows the dependence of Q_i on drive power P . In this case, the VNA was connected to device q_7 through highly attenuated microwave lines with an overall attenuation from the instrument to the sample of $-67 \pm 1 \text{ dB}$. This allows us to accurately estimate the average phonon population \bar{n} resulting from the coherent drive, shown in the upper scale of Fig. 4. A clear reduction in Q_i is observed as P is reduced, saturating at low power at a value of $Q_{i0} = 34\,500$. A similar dependence has been observed in bulk mechanical resonators [22,23] and electromagnetic coplanar waveguide resonators (CPWRs) [24] at low temperature, and has been attributed to coupling to a bath of two-level systems (TLS). The analytical expression of the loss rate caused by a TLS bath is given by [25]

$$\alpha_{\text{TLS}} = F \frac{2\pi^2 f_0 n_0 \gamma^2}{\rho v^2} \tanh\left(\frac{hf_0}{2k_B T}\right) \left(1 + \frac{P}{P_c}\right)^{-0.5},$$

where n_0 is the density of states of the TLS, ρ is the density of the crystal, P_c is a critical power, and γ describes the strength of the coupling between the TLS and the phonons. The filling factor F takes into account spatial variation of ρ and γ , due to the geometry of the SAW mode [26]. The internal quality factor is related to α_{TLS} by $Q_i = (v\alpha_{\text{TLS}}/\pi f_0 + 1/Q_{\text{rl}})^{-1}$, where Q_{rl} takes into account remaining losses. We find that our data fits well to this expression with $P_c = -65.7 \text{ dBm}$ and $F n_0 \gamma^2 = 4.5 \times 10^4 \text{ J/m}^3$. In order to completely validate this model and to estimate the value of F , temperature dependent measurement will be required [24,26]. The ratio $Q_{i0}/Q_{\text{rl}} \approx 0.6$ is much higher than typically seen in CPWRs [27], indicating that any TLS contribution to the loss is considerably less in the SAW case. Such a difference is qualitatively in agreement with an electric field coupling to the TLS bath, since in a weak piezoelectric such as quartz, only a small fraction of the SAW energy is electrical.

We finally comment on the prospects for realizing strong coupling cavity QED between a SAW resonator and a superconducting qubit, which requires a coupling strength g between qubit and resonator exceeding the linewidths of both [28]. The linewidth for resonator q_7 in the quantum regime is $\kappa = f/Q_i \approx 130 \text{ kHz}$, while a superconducting qubit on quartz may be expected to have linewidth $\gamma \lesssim 1 \text{ MHz}$ from experiments on GaAs, a similar piezoelectric

substrate [16]. The coupling strength can be estimated as $\hbar g = e\beta V_0^{\text{rms}}$ [29] where the electric potential due to the vacuum fluctuations of the SAW mode $V_0^{\text{rms}} \approx 20$ nV for a geometry similar to device q_7 , and β is a dimensionless parameter that takes into account the geometric match of the qubit to the SAW. For a superconducting qubit with well chosen geometry, $g \approx (0.2)eV_0^{\text{rms}}/\hbar \approx 2\pi \times 1$ MHz should be easily achievable. Coupling strengths in the 10–100 MHz range could be achieved in stronger piezoelectrics such as LiNbO₃ [18] or ZnO [30]. It should also be possible to couple in a similar way a wide variety of other solid-state quantum systems, such as quantum dots and crystal defect center spins, to SAW devices [31].

In summary, we have fabricated SAW resonators with a range of geometries and frequencies in the gigahertz range and measured them at cryogenic temperatures, demonstrating quality factors up to 4.5×10^5 . By measuring a range of different resonator lengths, we are able to place an upper limit on

propagation loss at 3.1 GHz and 10 mK of $\alpha_p \leq 0.015$ mm⁻¹. We observed a frequency dependence of Q_i for long resonators that suggests $\alpha_p \propto f^3$. In a highly isolated measurement setup, we observed a clear power dependence of the quality factor of a 4.4 GHz resonator consistent with coupling to a two-level system bath. We have demonstrated internal quality factors in the 10⁴ range up to 4.4 GHz, which should provide motivation for experiments that integrate SAW resonators with quantum coherent devices such as superconducting qubits.

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